

# Vakuové ventily

Dělení podle různých principů

Podle funkčnosti

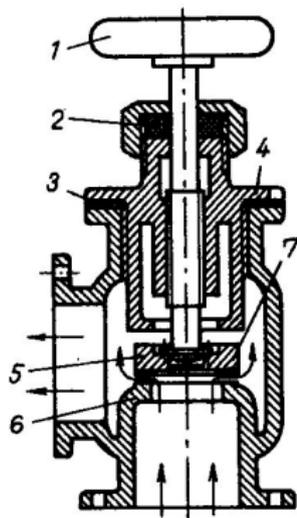
- oddělovací
- napouštěcí
- zavzdušňovací
- omezení čerpací rychlosti

Ovladání

- ruční
- pneumatický
- elektromagnetický

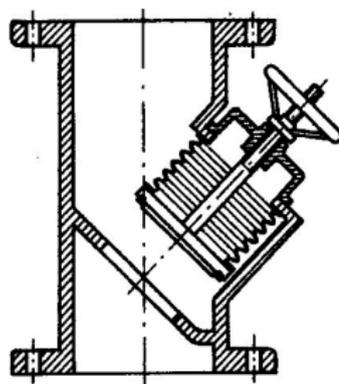
Oblast použití

- hrubé vakuum
- HV vakuum
- UHV, XHV vakuum



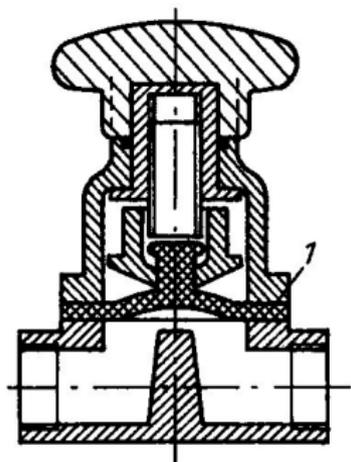
Obr. 6.27. Ventil s talířkem přitlačovaným šroubem

1 – rukojeť; 2 – těsnění; 3 – těsnicí kroužek; 4 – horní příruba; 5 – talířek; 6 – dolní příruba; 7 – těsnění talířku

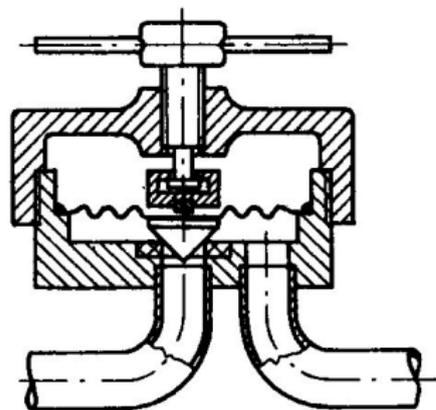


Obr. 6.28. Ventil těsněný vinovcem

J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981

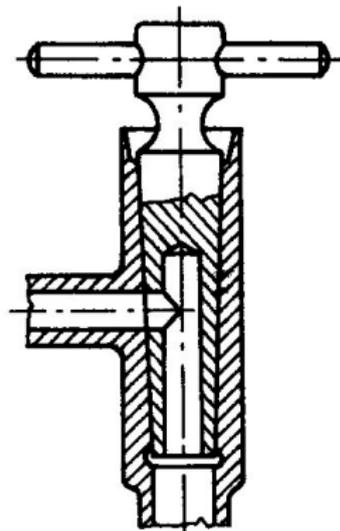
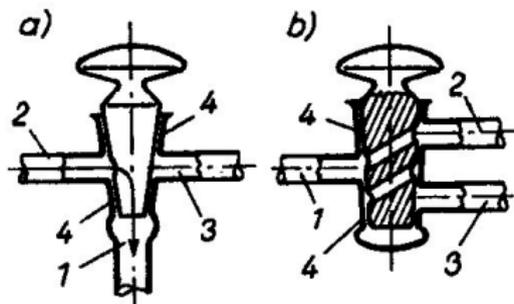


Obr. 6.32. Ventil pro nízké vakuum s membránovým těsněním (firma Leybold)



Obr. 6.33. Řez ventilu s kuželovým čepem a membránovým těsněním pro ultravysoké vakuum

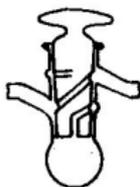
J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981



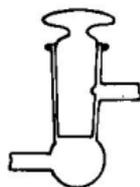
J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981



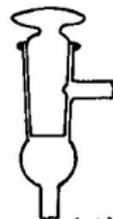
(a)



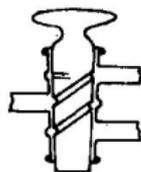
(b)



(c)



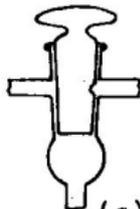
(d)



(e)



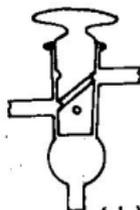
(f)



(g)



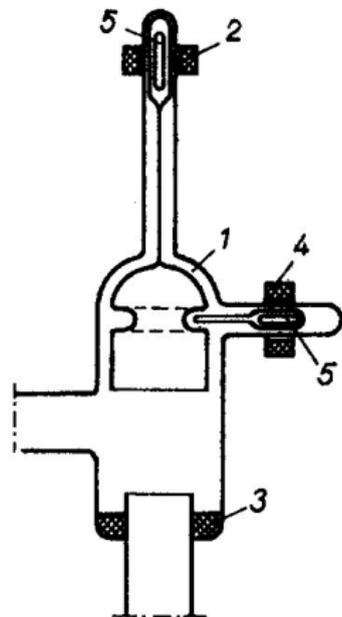
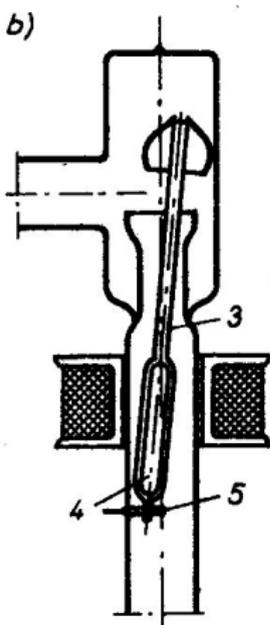
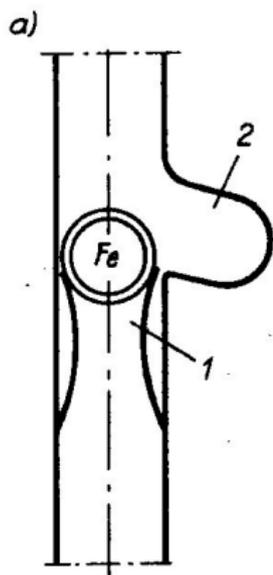
(h)



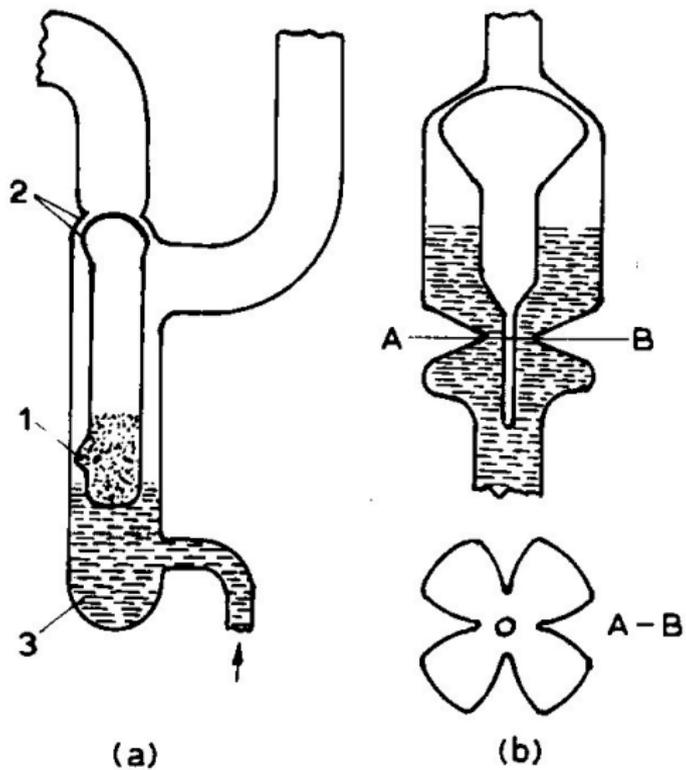
(i)



(j)



J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981



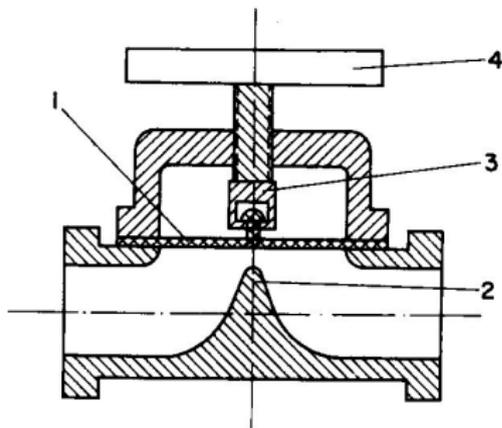
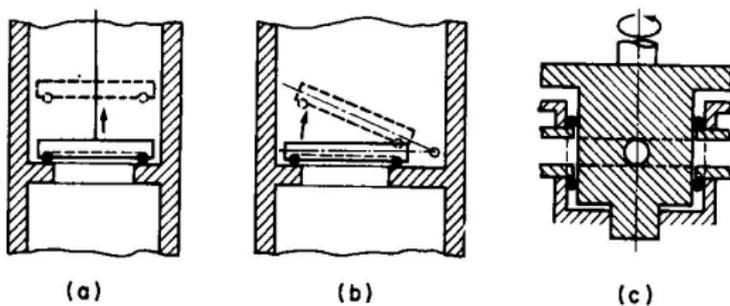
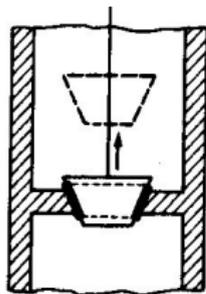
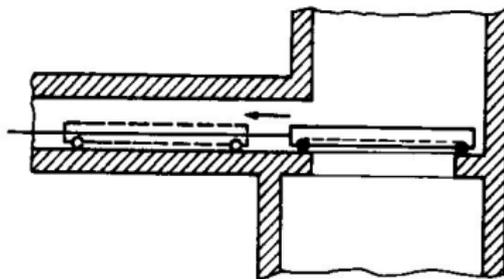


Fig. 7.61 Diaphragm valve.

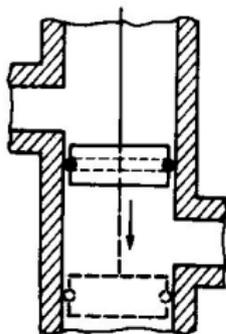




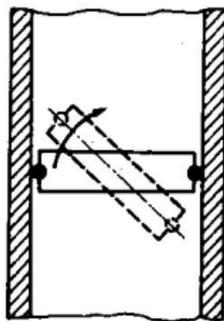
(d)



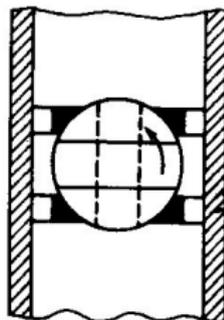
(e)



(f)



(g)



(h)

A. Roth: Vacuum technology, Elsevier, 1990

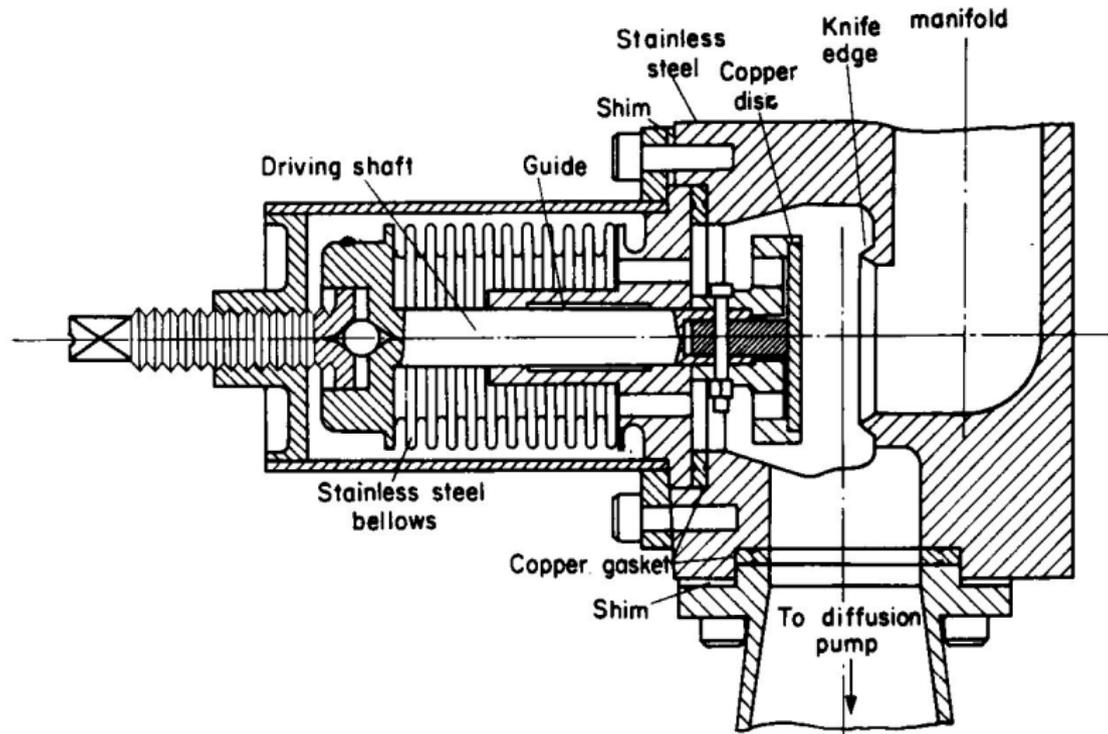


Fig. 7.65 Ultra-high vacuum valve. After Baker (1962).

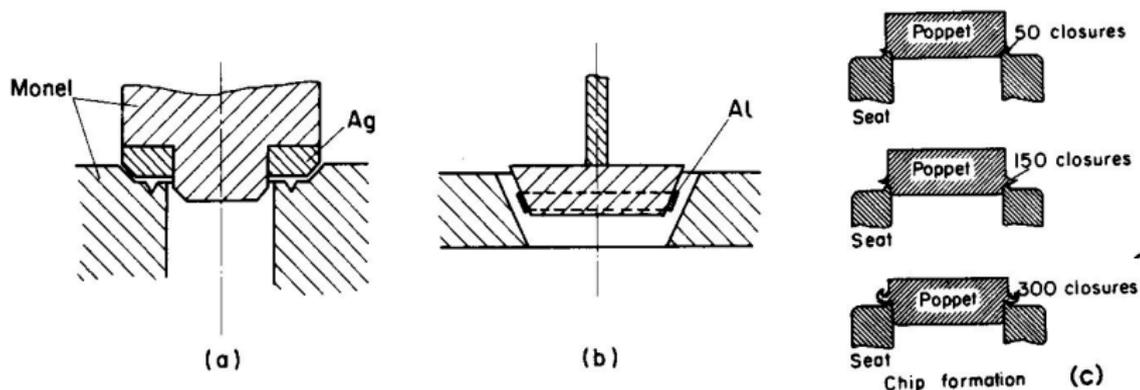
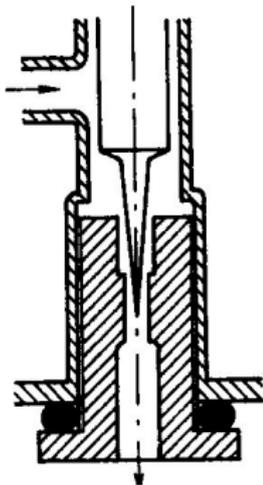


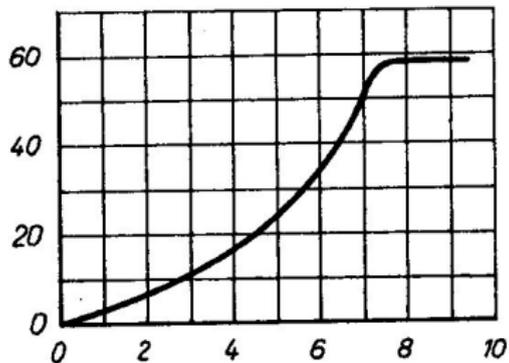
Fig. 7.63 Closing systems of all-metal valves; (a) with flat silver ring (Bills and Allen, 1955); (b) with aluminum conical ring (Kienel and Lorenz, 1960); (c) with copper poppet (Parker and Mark, 1961).

A. Roth: Vacuum technology, Elsevier, 1990

# Jehlový ventil



$I_N (\text{cm}^3(\text{NTP})\text{s}^{-1})$



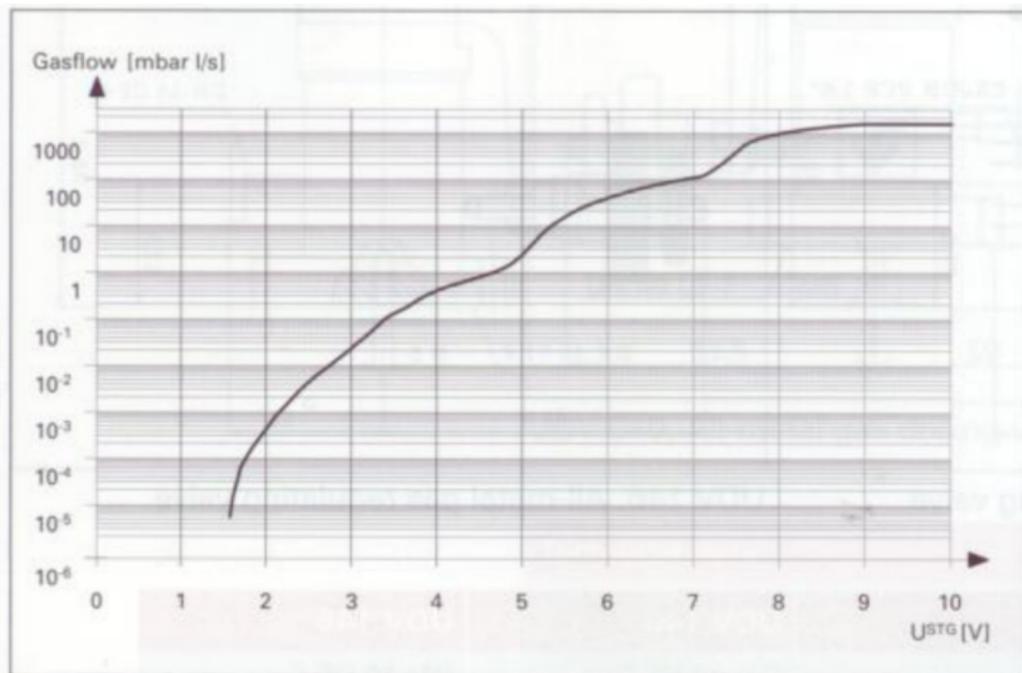
J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981

# EVN-116



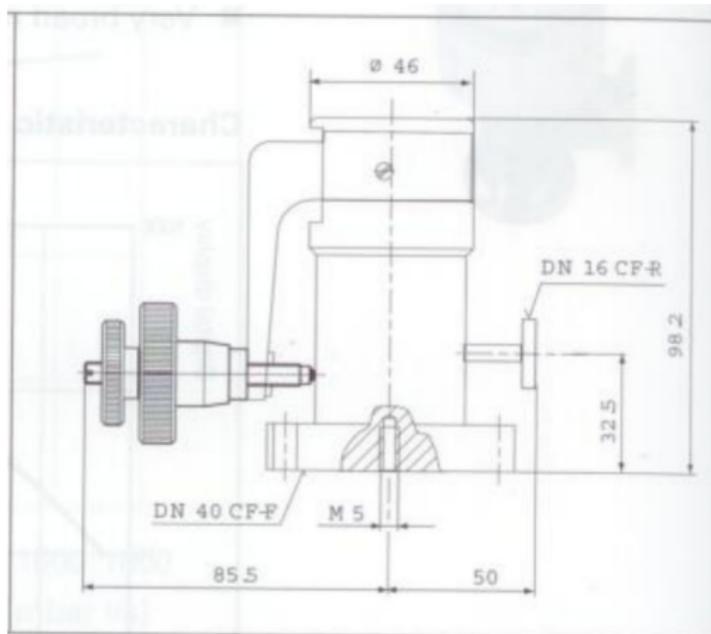
firemní mat. Pfeiffer

# EVR-116



EVR 116, Gas regulating valve

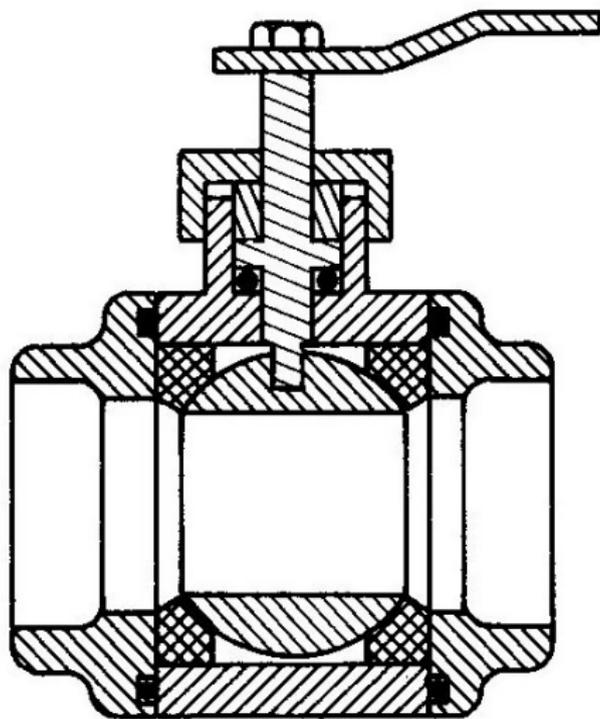
# UDV-046



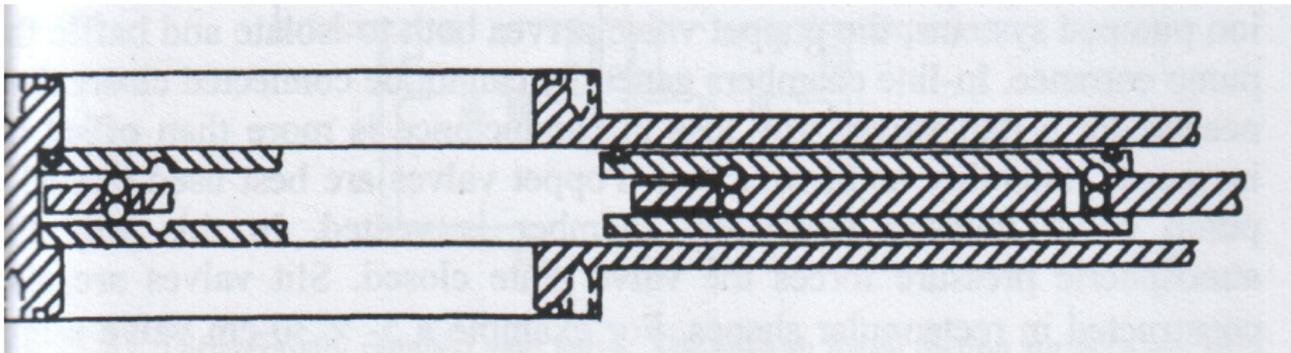
UDV 046, All-metal gas dosing valve

firemní mat. Pfeiffer min.  $1 \times 10^{-9}$  hPa/s

# Kulový ventil



# Deskový ventil



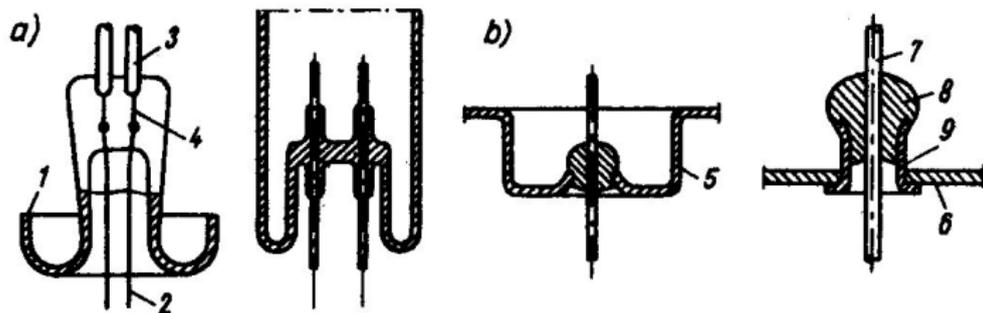
F.OHanlon: A Users Guide to Vacuum Technology, Wiley (2003)

- deskové ventily - při otevírání dif.tlak menší než  $\sim 30$  hPa
- ventily s kovovým těsněním - omezený počet cyklů
- jehlové ventily - nedotahovat silou
- zábrusové ventily - dobře namazat

# Elektrické průchodky

Vakuum v rozsahu tlaků 1 – 5000 Pa je velmi špatný elektrický izolant.  
Průchodky vybíráme podle:

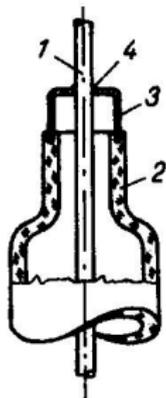
- napětí
- proudu
- frekvence



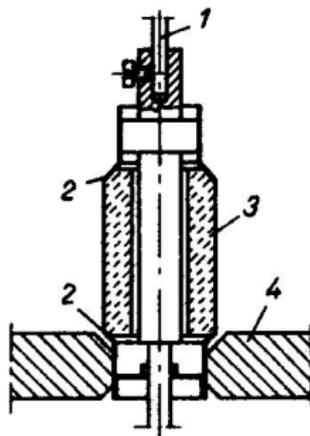
Obr. 6.47. Elektrické průchodky pro slabé proudy

a) vodič z plášťového nebo platinovaného drátku zataveného ve skle, b) průtav skleněnou perličkou zatavenou do otvoru v kovové stěně

J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981

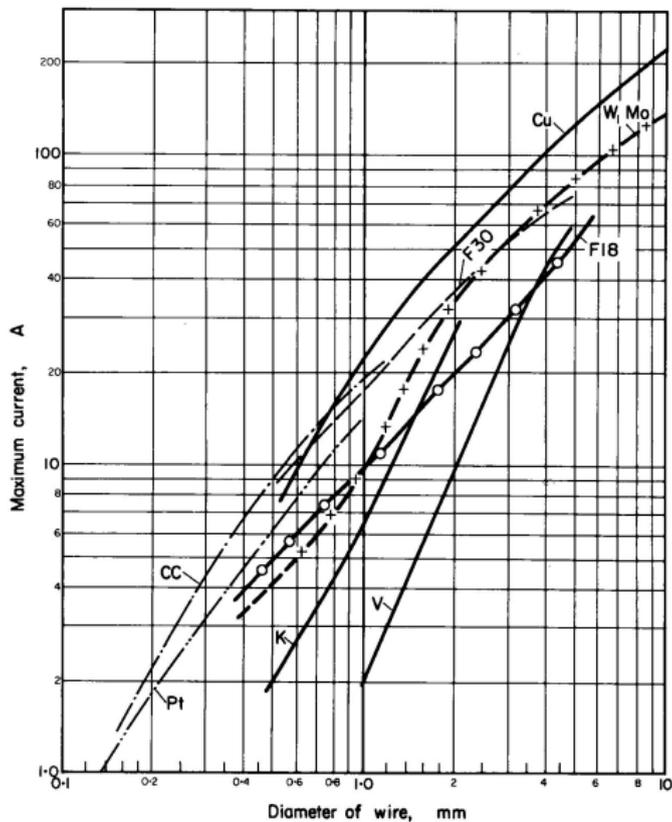


Obr. 6.48. Silnoproudá průchodka skleněnou trubicí  
 1 – průtav; 2 – sklo; 3 – kovarová čepička; 4 – pájka



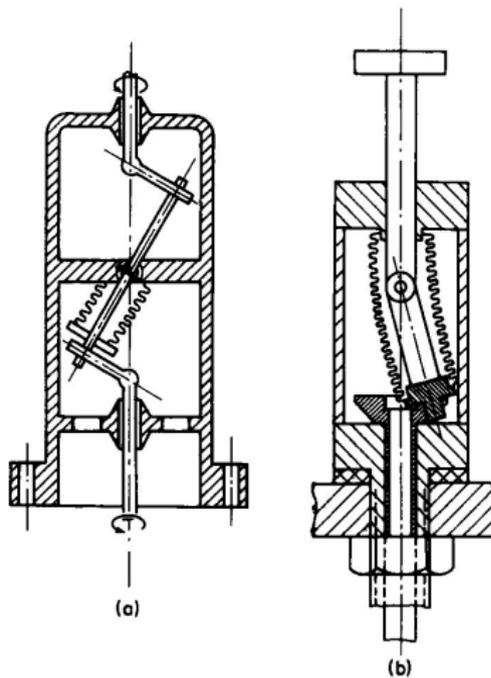
Obr. 6.49. Silnoproudá průchodka kovovou stěnou s keramickým izolátorem  
 1 – přívod; 2 – spoj kovu s keramikou; 3 – keramika; 4 – stěna vakuového systému

J. Groszkowski: Technika vysokého vakua, SNTL, Praha 1981

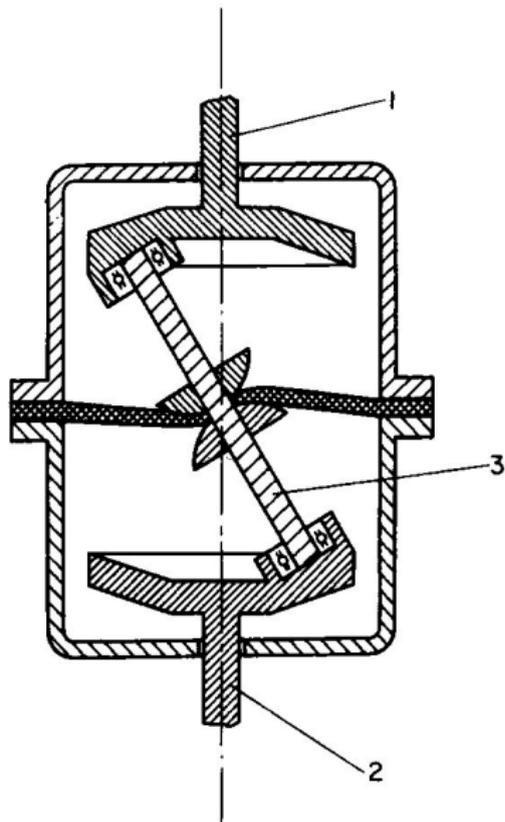


A. Roth: Vacuum technology, Elsevier, 1990

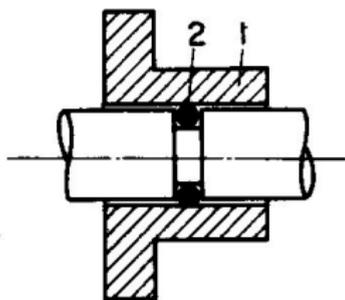
# Přenos rotace do vakua



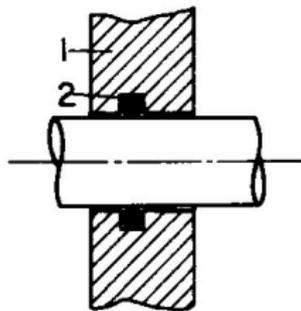
A. Roth: Vacuum technology, Elsevier, 1990



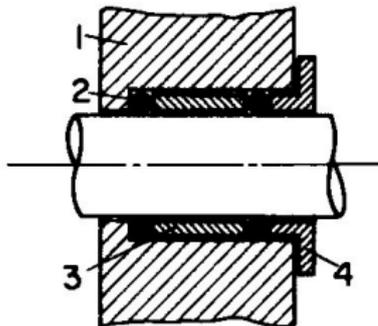
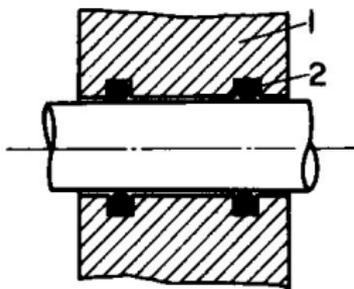
A. Roth: Vacuum technology, Elsevier, 1990



(a)

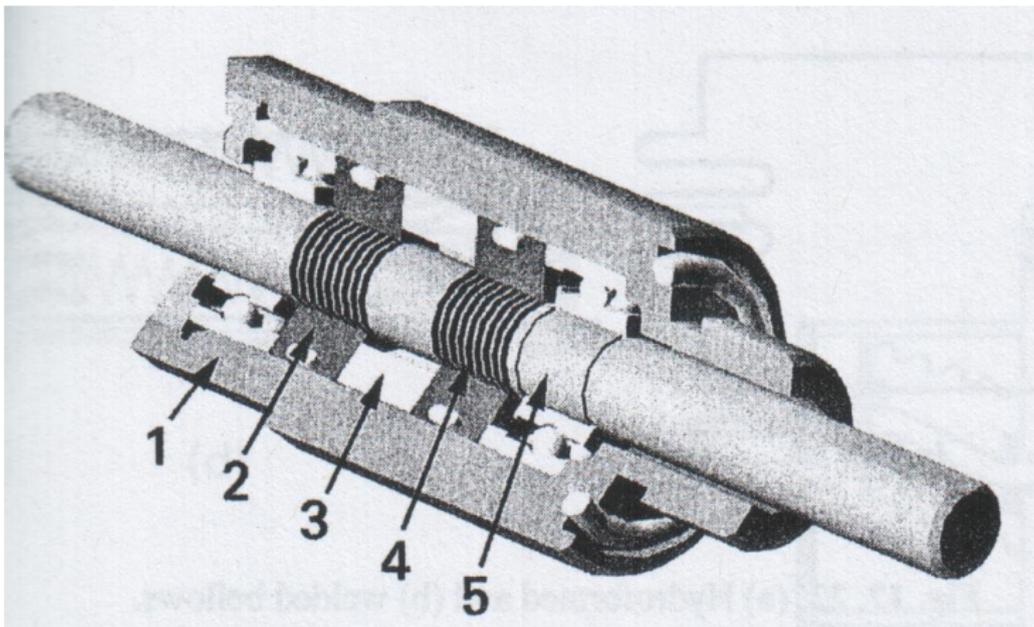


(b)



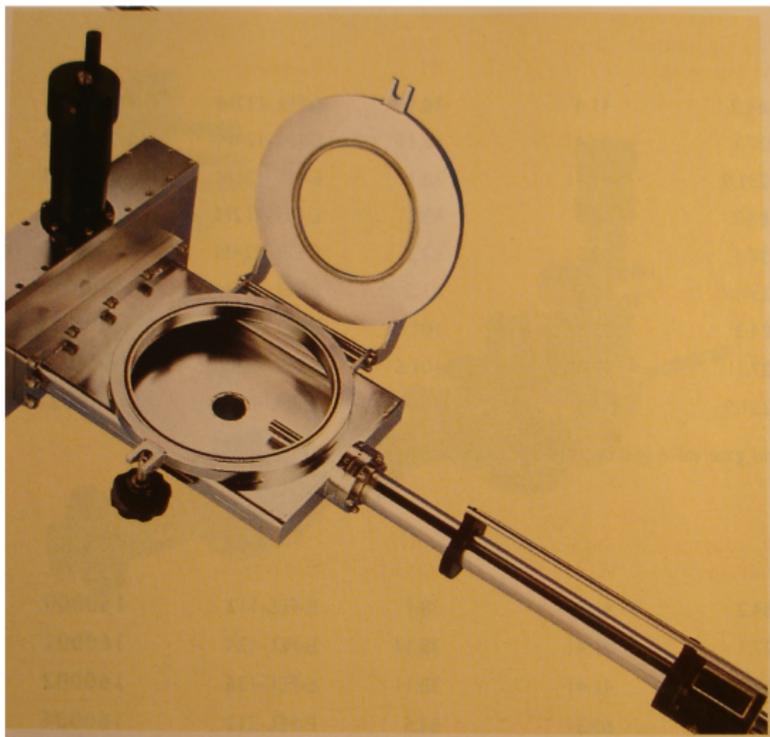
A. Roth: Vacuum technology, Elsevier, 1990

# Rotace - ferro kapaliny



F.OHanlon: A Users Guide to Vacuum Technology, Wiley (2003)

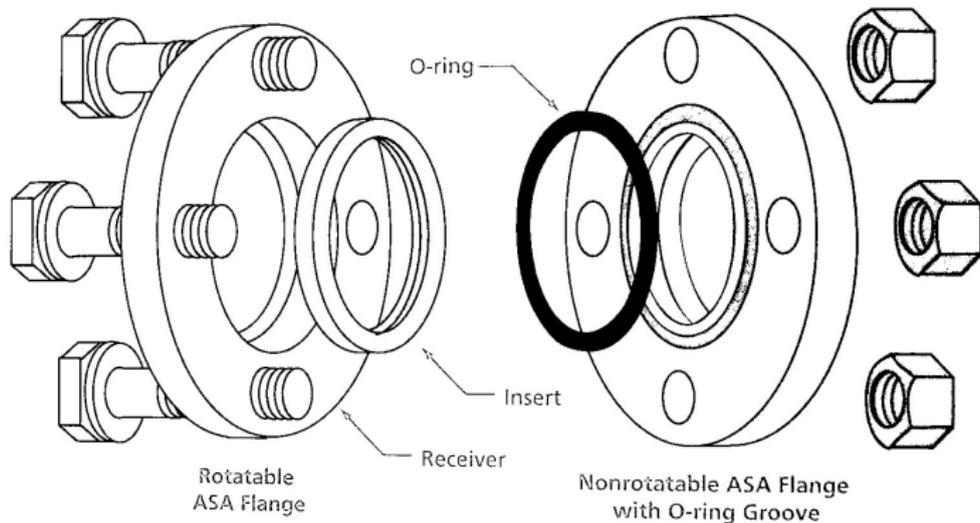
# Load lock



firemní materiály firmy Caburn MDC

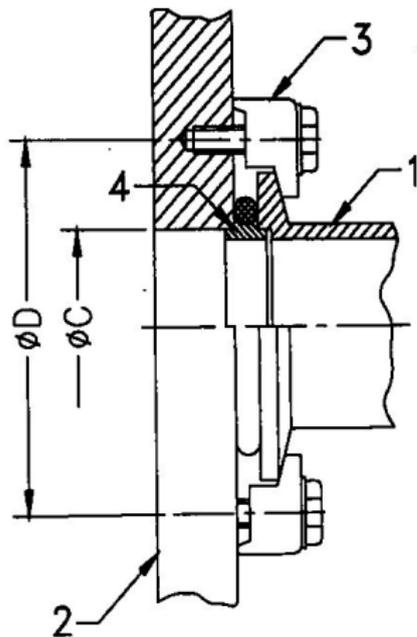
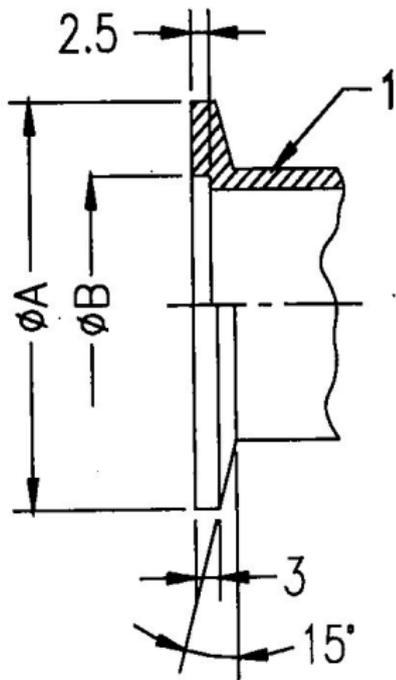
# Rozebirateľné spoje

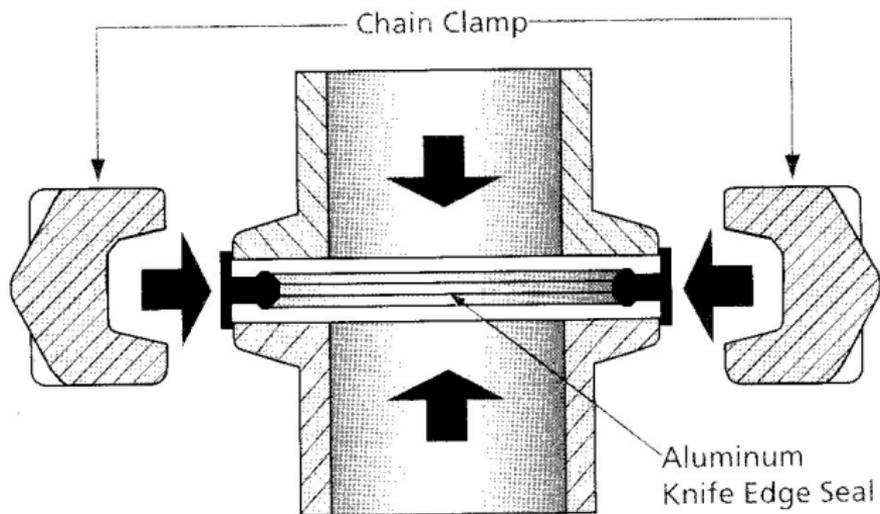
- ASA
- ISO-KF, (NW)
- ISO-K, ISO-F
- CF
- Wire seal flanges
- Helicoflex



firemní materiály firmy Nor-Cal

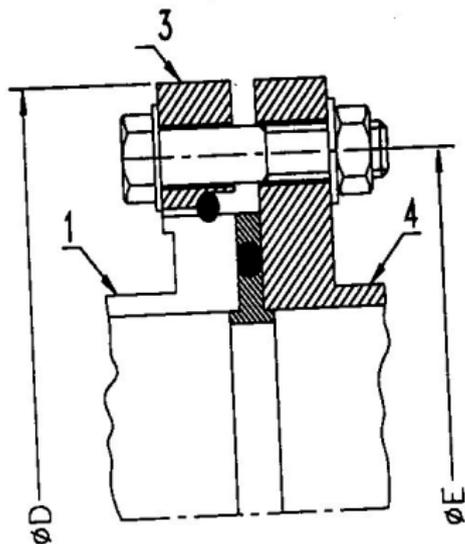
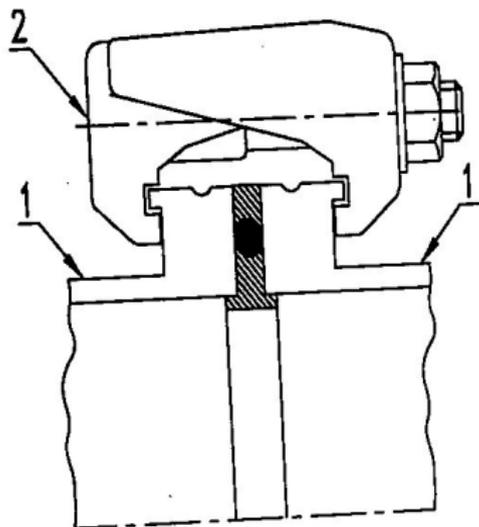
# ISO-KF



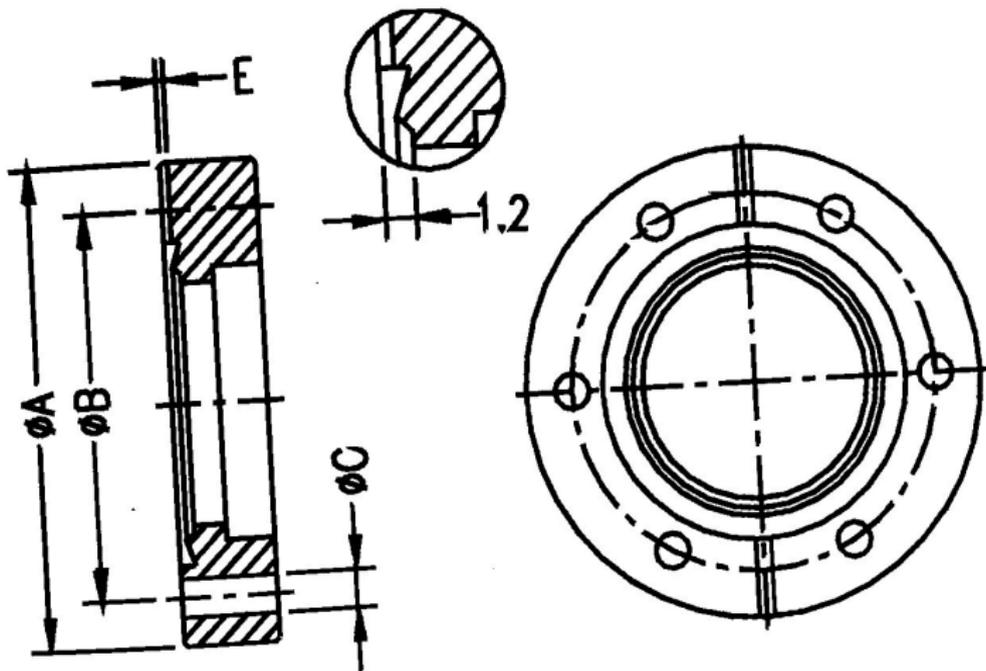


firemní materiály firmy Nor-Cal

# ISO-K, ISO-F



firemní materiály firmy Pfeiffer



firemní materiály firmy Pfeiffer

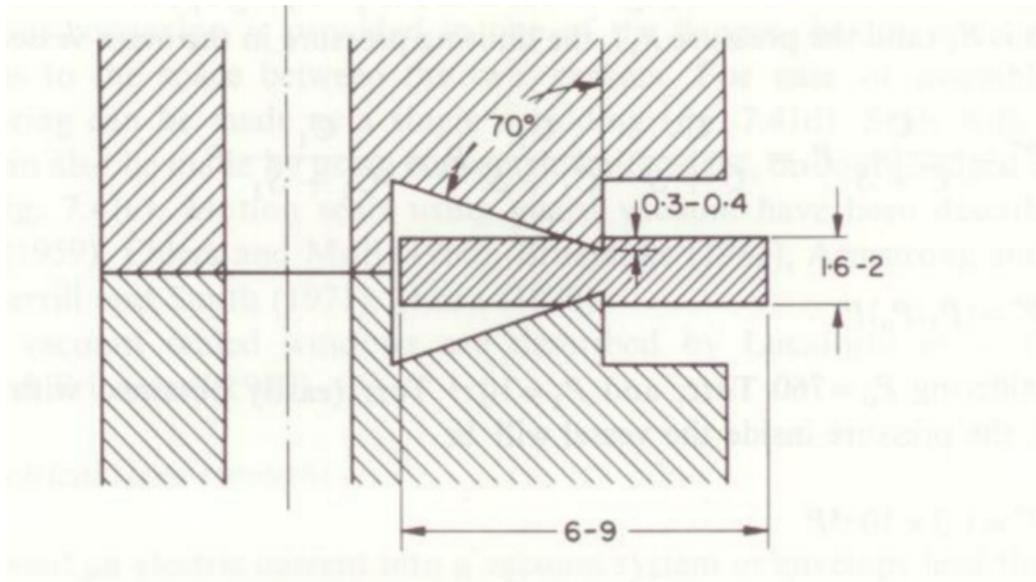
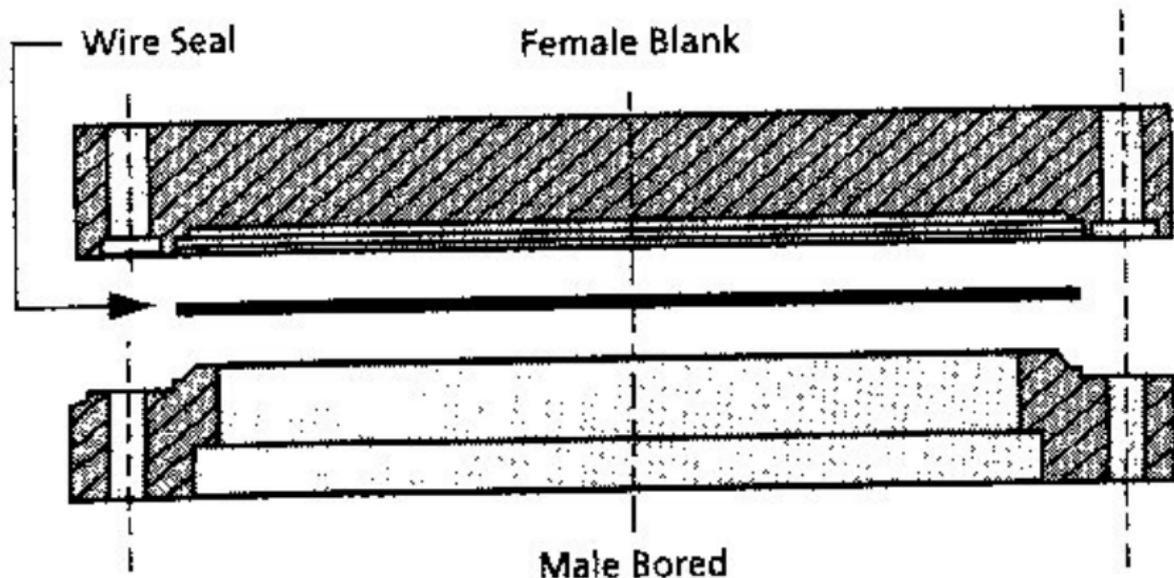


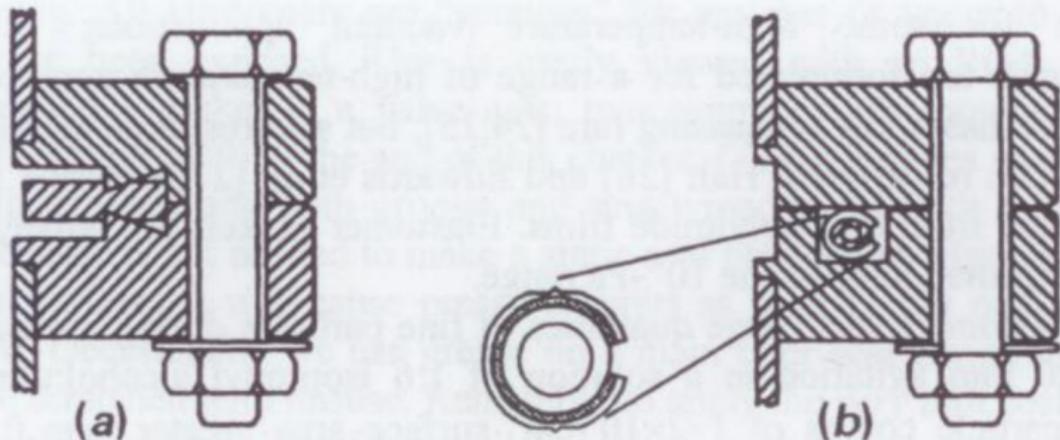
Fig. 7.39 The Conflat seal (Varian). After Wheeler and Carlson (1962).

A. Roth: Vacuum technology, Elsevier, 1990

# Wire seal flanges



firemní materiály firmy Nor-Cal



**Fig. 17. 10** Metal gasket seals: (a) ConFlat type knife edge seal; (b) Helicoflex Delta seal.

F.OHanlon: A Users Gaude to Vacuum Technology, Wiley (2003)

těsnění	min. tep [ °C]	max. tep. [ °C]
<b>elastomer</b>		
FKM	-15	150
NBR	-25	120
CR	-5	120
EPDM	-50	130
silikon	-55	200
<b>kov</b>		
Cu	-196	200
Cu + Ag	-196	450
Al	-196	150
In	-196	60

# Ohebné spoje

- připojení primárních vývěv
  - kovové vlnovce
    - bellows - změna délky při změně tlaku
    - flexible metal hose
  - tlustostěnné hadice
  - hadice s kovovou spirálou

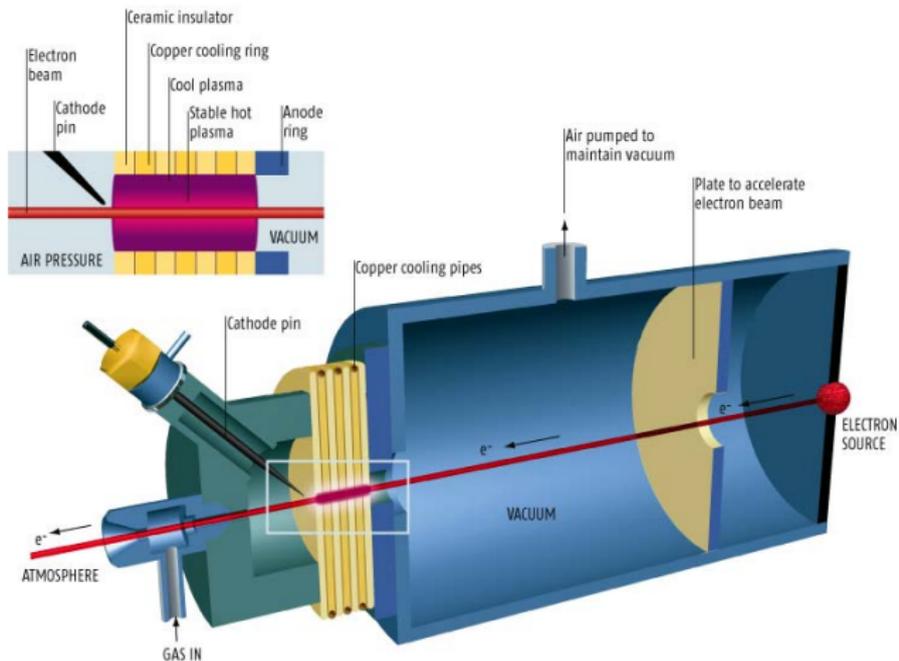
## Další prvky

- tlakové spínače
- 2D a 3D posuvy
- ohřev a rotace vzorků
- systémy pro povlakování
- plazmové okénko

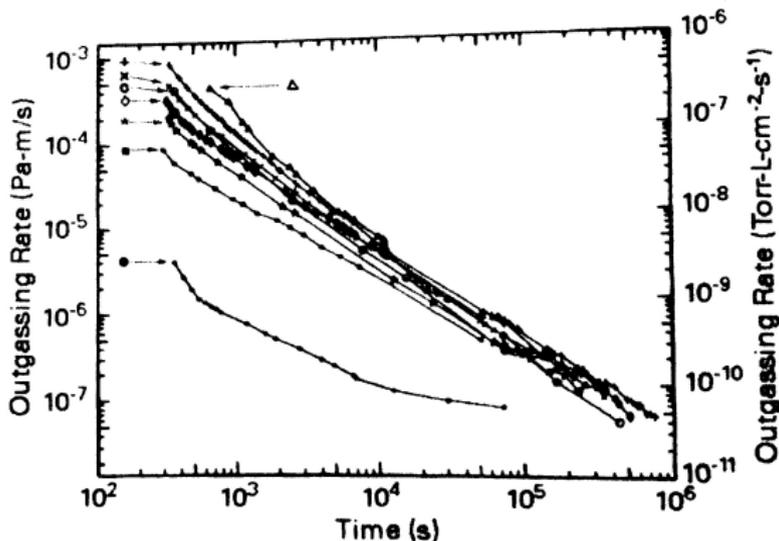
# Plazmové okno

## PLASMA WINDOW

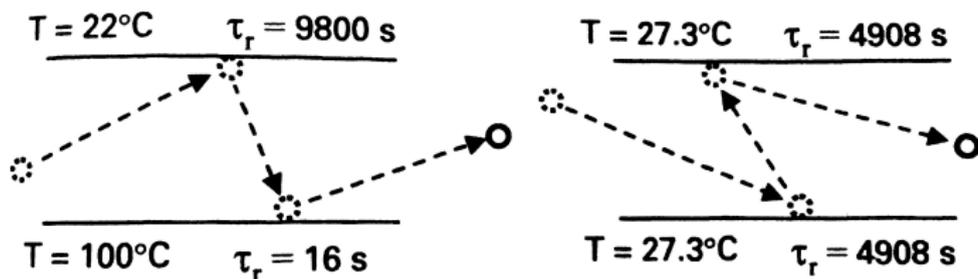
The stabilised plug of plasma seals the vacuum chamber to air but allows the electron beam to pass through



# Vodní pára ve vakuových systémech

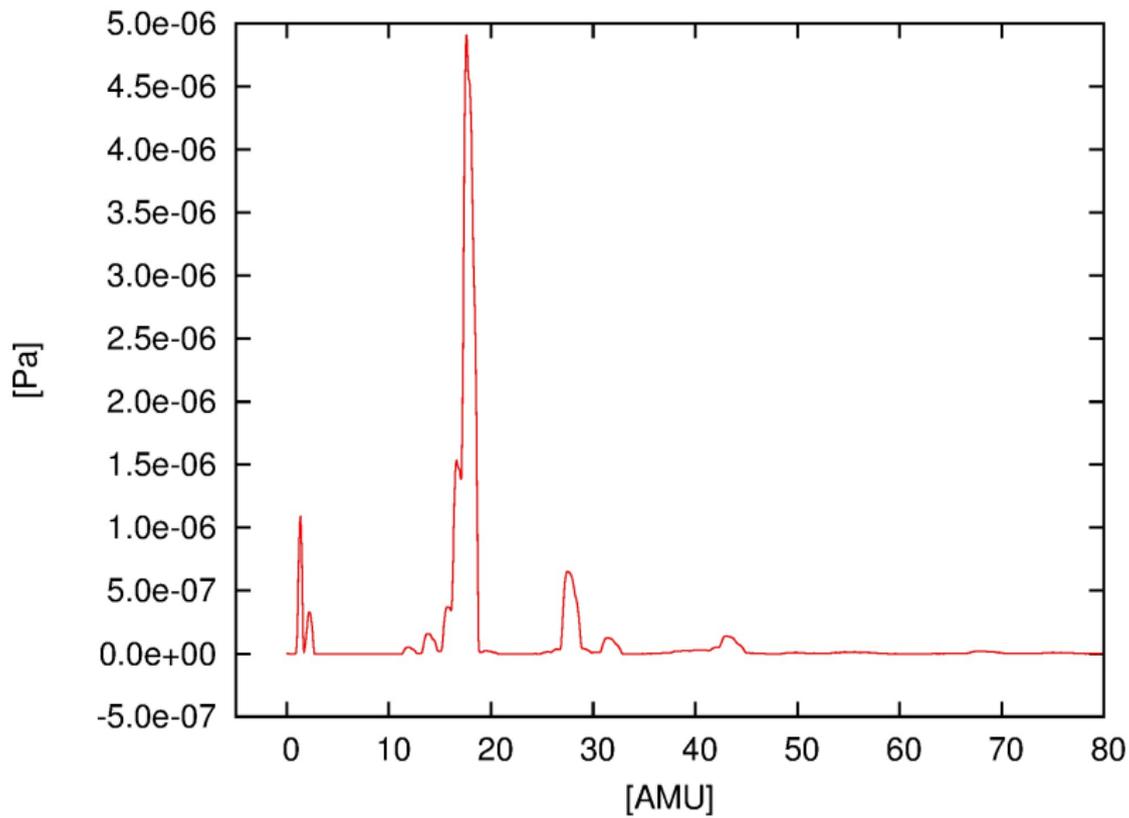


**Fig. 4.5** Outgassing measurements for different H<sub>2</sub>O exposures during venting of a 304 stainless steel chamber of inner surface area 0.4747 m<sup>2</sup>. ○ Ambient air exposed, 7.8 ml absorbed; Δ 600 ml exposed, 16.8 ml absorbed; + 400 ml exposed, 9.2 ml absorbed; × 200 ml exposed, 7.2 ml absorbed; ◇ 100 ml exposed, 3.6 ml absorbed; ★ 10 ml exposed, 2.3 ml absorbed; ■ N<sub>2</sub> gas with <10 ppm H<sub>2</sub>O exposed, 0.7 ml absorbed; ● dry N<sub>2</sub> gas exposed, 0.017 ml absorbed; Reprinted with permission from *J. Vac. Sci. Technol. A*, 11, p. 1702, M. Li and H. F. Dylla. Copyright 1993, AVS-The Science and Technology Society.

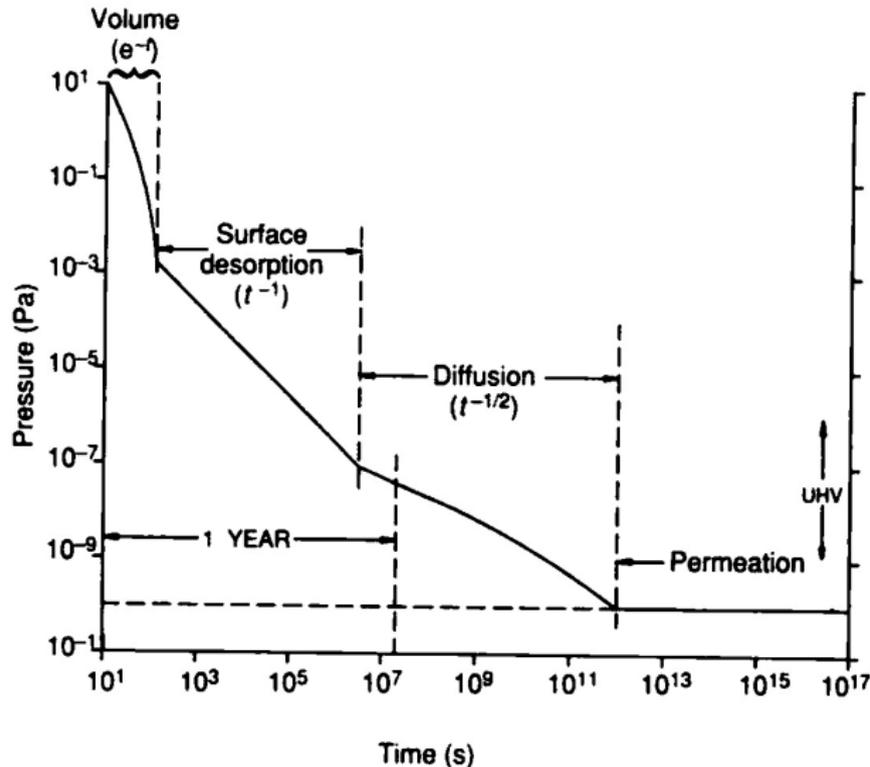


**Fig. 4.8** The total residence time for a water molecule after two bounces from a metal surface is shown to be the same for two sets of surface temperatures; a sticking coefficient of one was assumed. This example illustrates the necessity of baking all surfaces within a vacuum chamber. Unbaked surfaces dominate the behavior of the system.

F.OHanlon: A Users Guide to Vacuum Technology, Wiley (2003)



# Typická křivka čerpání vakuové komory bez vypékání



Delchar: Vacuum Physics and Techniques, Chapman Hall, 1993

# Česká vakuová společnost

- zpravodaj
- Pragovak
- Letní školy vakuové techniky
- [www.vakspol.cz](http://www.vakspol.cz)